Experimental demonstration and analysis of compact silicon-nanowire-based couplers

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Abstract
Compact 2 x 2 couplers based on silicon nanowires are fabricated and tested. They include a directional (X) coupler, a cross-gap coupler (CGC), and a multimode interference (MMI) coupler. The length of the X coupler's parallel film waveguide is 1 μm. The theoretical minimum excess loss of the X coupler is 0.73 dB, whereas its experimental value is 1.0817 dB. CGC has a coupling region length of 24 μm. The minimum excess loss of CGC, which is 0.6 dB in theory, is experimentally determined to be 0.6737 dB. Taper waveguides are used as input/output waveguides for the MMI coupler. The footprint of the MMI region is only 6 x 57 μm2. The excess loss of the MMI coupler is theoretically 0.46 dB, but its experimental value is 0.5423 dB. The experimental nonuniformity of the MMI coupler is 0.0063 dB when the center wavelength is 1.55 μm. The maximum excess loss of the MMI coupler is 0.8233 dB in the wavelength range of 1.52 to 1.58 μm. The simulated and experimental results show that a small 2 x 2 MMI coupler that is suitable for optoelectronic integration exhibits lower excess loss, wider bandwidth, and better uniformity.

Keywords
compact, analysis, couplers, demonstration, nanowire, experimental, silicon

Disciplines
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1 Introduction

In the optical fiber grating demodulation system, optical couplers have irreplaceable and important functions. The development of low-cost, high-performance optical couplers with high-level integration is necessary and urgent to meet the requirements of demodulation systems. In 2008, Chen introduced the application of a femtosecond fiber laser to fabricate broadband directional (X) couplers inside bulk glass for general power-splitting applications within the telecom spectrum with wavelengths of 1250 to 1650 nm; the coupling region length of the said coupler was 0.1 mm. Simultaneously, Yang designed and fabricated a 2 × 2 tapered multimode interference (MMI) coupler using an air-cladded SU-8 rectangular waveguide with a total MMI size of approximately 5.3 × 34.2 μm², an excess loss of 1.3 dB, and a nonuniformity of ~0.8 dB. In 2010, Tanaka proposed and designed a CGC based on silicon-on-insulator (SOI) technology. Meanwhile, Halir designed a colorless X coupler with a dispersion-engineered subwavelength structure in 2012; this coupler covered a 100 nm bandwidth with an imbalance of less than 0.6 dB.

The aforementioned 2 × 2 couplers were applied in different optical devices. These couplers have the advantage of either a wider bandwidth or a smaller footprint. Here, we have designed a silicon-nanowire-based X coupler, CGC, and a multimode interference (MMI) coupler. The length of the X coupler’s parallel film waveguide is 1 μm. The theoretical minimum excess loss of the X coupler is 0.73 dB, whereas its experimental value is 1.0817 dB. CGC has a coupling region length of 24 μm. The minimum excess loss of CGC, which is 0.6 dB in theory, is experimentally determined to be 0.6737 dB. Taper waveguides are used as input/output waveguides for the MMI coupler. The footprint of the MMI region is only 6 × 57 μm². The excess loss of the MMI coupler is theoretically 0.46 dB, but its experimental value is 0.5423 dB. The experimental nonuniformity of the MMI coupler is 0.0063 dB when the center wavelength is 1.55 μm. The maximum excess loss of the MMI coupler is 0.8233 dB in the wavelength range of 1.52 to 1.58 μm. The simulated and experimental results show that a small 2 × 2 MMI coupler that is suitable for optoelectronic integration exhibits lower excess loss, wider bandwidth, and better uniformity. © 2013 Society of Photo-Optical Instrumentation Engineers (SPIE) [DOI: 10.1117/1.OE.52.6.064003]

Subject terms: optical devices; silicon-nanowire; coupler; loss; optoelectronic integration.

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2 Fabrication and Testing of 2 × 2 Couplers

2.1 Fabrication Process and Testing System

SOI is selected as the material for the simulation and fabrication of the couplers. SOI is a prominent platform for microelectronics and optoelectronics, which can be used in optical device interconnections and applied in military devices. This material is superior in terms of its compatibility with silicon processing, convenient electronic or photonic integration, waveguide characteristics, facile operation in optical circuits, and radioprotection. Bent waveguides with smaller radii of curvature can be realized on SOI substrates. Extremely small devices can be fabricated on SOI substrates because of the ultrahigh contrast between the refractive indices of Si and SiO₂. The original equipment manufacturer of our designed coupler is Institute of Microelectronics (IME) from Singapore. The bare SOI wafer used during fabrication had the following parameters: (1) buried SiO₂ with a thickness of 2 μm and a refractive index of 1.45; and (2) top Si layer, with a thickness of 220 nm and a refractive index of 3.46. The standard fabrication process used by IME for optical couplers is schematically shown in Fig. 1. Here, 248-nm lithography is used.
A tunable laser is used on the C-band during testing. The SMF-28 with a tapered tip at one end is selected to couple the light source and the chips. The coupling efficiency of the tapered fiber and the waveguides is approximately 50%. During the testing process, an infrared microscope with a camera is used to observe the output of the couplers.

### 2.2 X Coupler Testing

The X coupler is based on the power exchange principle between two waveguides approaching each other. The coupling region of the X coupler periodically exchanges energy by coupling between the two parallel film waveguides. The splitting ratio can be controlled by adjusting the parameters of the coupling region. The coupling length can be expressed as:

$$L = \frac{\pi}{(n_e - n_o)k_0},$$

where $n_e$ and $n_o$ are the effective refraction indexes of the even and odd symmetrical modes, respectively. $k_0$ is the vacuum vector. The coupling length for a 3 dB X coupler is expressed as:

$$L_{3 \text{ dB}} = \frac{L}{2} = \frac{\pi}{2(n_e - n_o)k_0}.$$  (2)

The X coupler is simulated via BeamPROP simulation engine, which is a part of the RSoft Photonics Suite, and is based on advanced finite-difference beam propagation techniques. The waveguide width is expressed as $w$. The distance between two parallel film waveguides is expressed as $s$. X couplers with different $w$ and $s$ are simulated, and the best simulation result is presented in Fig. 2.

The micrographs of the fabricated X coupler are shown in Fig. 3. A representative charge-coupled device (CCD) image of the output field is shown in Fig. 4. When the center wavelength is 1.55 $\mu$m, the excess loss of the device is approximately 0.73 dB based on the simulation results. However, its experiment value is 1.0817 dB. The simulated and experimental results are compared in Table 1. CR represents the splitting ratio:

$$\text{CR} = \frac{P_{\text{OUTi}}}{\Sigma P_{\text{OUTi}}} \times 100\%,$$  (3)

where $P_{\text{OUTi}}$ is the output power from the coupler’s output port $i$.

![Fig. 2](http://opticalengineering.spiedigitallibrary.org/) Optical field and output power of the X coupler when $w = 0.55$ and $s = 0.2$ $\mu$m. “1, Launch” represents the light power of the X coupler’s input waveguide, “2, Launch” represents the light power of the X coupler’s coupling waveguide.

![Fig. 3](http://opticalengineering.spiedigitallibrary.org/) Micrographs of the X coupler.

![Fig. 4](http://opticalengineering.spiedigitallibrary.org/) Charge-coupled device (CCD) image for the output field of the X coupler when $w = 0.55$ and $s = 0.2$ $\mu$m.
UL represents the nonuniformity:

\[ \text{UL} = 10 \log \frac{P_{\text{OUTi}}}{P_{\text{OUT}}} \]  

(4)

IL1 and IL2 represent the insert loss of the bar and cross paths, respectively:

\[ \text{ILi} = -10 \log \frac{P_{\text{OUTi}}}{P_{\text{IN}}} \]  

(5)

where \( P_{\text{IN}} \) is the input power from the one of the coupler’s output ports.

EL represents the excess loss:

\[ \text{EL} = -10 \log \frac{\sum P_{\text{OUTi}}}{P_{\text{IN}}} \]  

(6)

The difference between the simulated and experimental nonuniformity of the X coupler is relatively large (Table 1). This difference is caused by the fabrication tolerance because the X coupler is highly sensitive to the coupling length.

### 2.3 CGC Testing

A CGC is a coupler that has an X-junction with an internal cross-sectional mirror. The gap in the CGC between the two waveguides functions as a half mirror. The principles of CGCs are similar to those of X couplers. However, these two types of couplers differ in their input/output waveguides, such that only those of CGCs are linear.

Similar to the X coupler, the waveguide width for the CGC system is expressed as \( w \), whereas its gap is expressed as \( s \). CGCs with different values for \( w \) and \( s \) are simulated, and the best simulation result is shown in Fig. 5.

The micrographs and detailed parameters of the CGC are shown in Fig. 6. The CCD image of the output field is shown in Fig. 7. When the center wavelength is 1.55 \( \mu \)m, the excess loss of the device is \( \sim 0.6 \) dB according to the simulations, whereas its experimental value is 0.637 dB. The simulated and experimental results are compared in Table 2. This table shows that the differences between the simulated and experimental results are relatively small.

Bent waveguides with straight lines can induce a transverse coupling effect. Thus, after the connection of bent waveguides, the original coupling region becomes longer. The splitting ratio can be kept constant if the bent waveguides are followed by a reduced coupling region length. Moreover, bent waveguides are harder to fabricate. Thus, a CGC has better performance and a relatively higher fabrication tolerance than an X coupler with the same footprint.

#### Table 1 Comparison of X coupler properties.

<table>
<thead>
<tr>
<th>CR</th>
<th>UL (dB)</th>
<th>IL1 (dB)</th>
<th>IL2 (dB)</th>
<th>EL (dB)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Sim</td>
<td>0.2050</td>
<td>3.8439</td>
<td>3.6389</td>
<td>0.73</td>
</tr>
<tr>
<td>Exp</td>
<td>2.0347</td>
<td>3.0850</td>
<td>2.8179</td>
<td>5.9029</td>
</tr>
</tbody>
</table>

#### Table 2 Comparison of cross-gap coupler (CGC) properties.

<table>
<thead>
<tr>
<th>CR</th>
<th>UL (dB)</th>
<th>IL1 (dB)</th>
<th>IL2 (dB)</th>
<th>EL (dB)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Sim</td>
<td>0.9917</td>
<td>0.0363</td>
<td>3.6289</td>
<td>3.5924</td>
</tr>
<tr>
<td>Exp</td>
<td>0.9693</td>
<td>0.1355</td>
<td>3.7523</td>
<td>3.6168</td>
</tr>
</tbody>
</table>

#### 2.4 Testing the 2 x 2 MMI Couplers

The MMI coupler is based on the self-imaging principle\(^{10,11}\) and has three interference mechanisms: general, paired, and symmetrical.

Paired interference is selected for this paper. Input waveguides are set in the position \( \pm w_c / 6 \) of the multimode waveguide:

\[ w_c = w + \frac{\lambda_0}{\pi} \left( \frac{n_s}{n_r} \right)^2 \left( n_r^2 - n_s^2 \right)^{\frac{1}{2}}, \]  

(7)

where \( w \) is the multimode waveguide width and \( \lambda_0 \) is the center wavelength. In this equation, \( \sigma = 0 \) for the transverse

Image captions:

**Fig. 5** Optical field and output power of cross-gap coupler (CGC) when 0.55 and \( s = 0.2 \) \( \mu \)m. "1. Launch" represents the light power of the CGC’s input waveguide, "2. Launch" represents the light power of the CGC’s coupling waveguide.

**Fig. 6** Micrographs of CGC.

**Fig. 7** CCD image for the CGC output field when \( w = 0.55 \) and \( s = 0.2 \) \( \mu \)m.
electric (TE) mode, whereas $\sigma = 1$ for the transverse magnetic (TM) mode. $n_c$ and $n_r$ are the effective refractive indexes of the cladding and the core, respectively.

The multimode waveguide length can be expressed as:

$$L_{\text{MMI}} = \frac{L_{\pi}}{2} = \frac{\pi}{2(\beta_0 - \beta_1)} \approx \frac{2nw_c^2}{3\lambda_0},$$

(8)

where $L_{\pi}$ represents the coupling length of the two lowest order modes. $\beta_0$ and $\beta_1$ are the propagation constants of the lateral modes 0 and 1, respectively.

The multimode waveguide width is expressed as $w$. A comparison of MMI coupler properties with different $w$ according to the simulation results is presented in Table 3.

MMI couplers with $w$ of 15 and 6 $\mu$m are fabricated and tested in this study. The optical field and output power of the MMI coupler when $w = 15\ \mu$m is shown in Fig. 8.

The micrographs of the MMI coupler when $w = 15\ \mu$m are shown in Fig. 9. The CCD image of the output field is shown in Fig. 10. When the center wavelength is 1.55 $\mu$m, the excess loss of the device is approximately 0.09 dB based on the simulation. However, its experimental excess loss is 0.1418 dB. A comparison of the simulated and experimental results is presented in Table 4. From this table, the difference between the simulated and experimental values is extremely small.

The output power of the MMI coupler when the center wavelength ranged from 1.52 to 1.58 $\mu$m is shown in Fig. 11, where the maximum excess loss is 0.2871 dB. $P$ represents the output power of the light source, whereas $P_0$ represents the output power of a straight waveguide. $P_1$ and $P_2$ represent the output power values of the coupler’s bar and cross paths, respectively. The experimental results show that the designed coupler has a wide range of wavelength responses.

The optical field and output power of the MMI coupler when $w = 6\ \mu$m are illustrated in Fig. 12. Input/output waveguides are designed as tapered waveguides during the optimization process to make the image point clearer, to improve the splitting ratio, and to reduce loss.

---

**Table 3** Comparison of MMI coupler properties with different $w$.  

<table>
<thead>
<tr>
<th>$w$ ((\mu)m)</th>
<th>CR</th>
<th>UL (dB)</th>
<th>IL1 (dB)</th>
<th>IL2 (dB)</th>
<th>EL (dB)</th>
</tr>
</thead>
<tbody>
<tr>
<td>48</td>
<td>1.03</td>
<td>0.1284</td>
<td>2.9964</td>
<td>3.1256</td>
<td>0.05</td>
</tr>
<tr>
<td>24</td>
<td>0.98</td>
<td>0.0877</td>
<td>3.1149</td>
<td>3.0260</td>
<td>0.06</td>
</tr>
<tr>
<td>15</td>
<td>0.99</td>
<td>0.044</td>
<td>3.1220</td>
<td>3.0786</td>
<td>0.09</td>
</tr>
<tr>
<td>12</td>
<td>0.985</td>
<td>0.0656</td>
<td>3.2431</td>
<td>3.1776</td>
<td>0.2</td>
</tr>
<tr>
<td>6</td>
<td>1.013</td>
<td>0.06</td>
<td>3.4448</td>
<td>3.4960</td>
<td>0.46</td>
</tr>
</tbody>
</table>

---

**Table 4** Comparison of MMI coupler properties when $w = 15\ \mu$m.  

<table>
<thead>
<tr>
<th></th>
<th>CR</th>
<th>UL (dB)</th>
<th>IL1 (dB)</th>
<th>IL2 (dB)</th>
<th>EL (dB)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Simulation</td>
<td>0.99</td>
<td>0.044</td>
<td>3.1220</td>
<td>3.0786</td>
<td>0.09</td>
</tr>
<tr>
<td>Experimental</td>
<td>1.0122</td>
<td>0.0053</td>
<td>3.1495</td>
<td>3.1547</td>
<td>0.1418</td>
</tr>
</tbody>
</table>

---

**Fig. 8** Optical field and output power of the MMI coupler when $w = 15\ \mu$m. “1, Launch” represents the light power of the MMI coupler’s input waveguide, “2, Launch” represents the light power of the MMI coupler’s left output waveguide, “3, Launch” represents the light power of the MMI coupler’s right output waveguide.

**Fig. 9** Micrographs of the MMI coupler when $w = 15\ \mu$m.

**Fig. 10** CCD image for output field of the MMI coupler when $w = 15\ \mu$m.

**Fig. 11** Output power for MMI coupler when $w = 15\ \mu$m.
The micrographs of the MMI coupler when $w = 6 \mu m$ are shown in Fig. 13, whereas the CCD image of its output field is presented in Fig. 14. When the center wavelength is 1.55 $\mu$m, the excess loss of this device is approximately 0.46 dB based on the simulated results, but is 0.5423 dB according to the actual experiment. The excess loss is larger when $w = 6 \mu m$ than when $w = 15 \mu m$ although the footprint is much smaller. The simulated and experimental results of this MMI coupler are compared in Table 5. From this table, the differences between the results of the simulation and the experiment are small.

![Fig. 12](image1.png)

**Fig. 12** Optical field and output power of the MMI coupler with a tapered input/output waveguide when $w = 6 \mu m$. "1. Launch" represents the light power of the MMI coupler's input waveguide, "2. Launch" represents the light power of the MMI coupler's left output waveguide, "3. Launch" represents the light power of the MMI coupler's right output waveguide.

![Fig. 13](image2.png)

**Fig. 13** Micrographs of the MMI coupler when $w = 6 \mu m$.

![Fig. 14](image3.png)

**Fig. 14** CCD image for output field of the MMI coupler when $w = 6 \mu m$.

The output power of the MMI coupler when the center wavelength ranged from 1.52 to 1.58 $\mu m$ is demonstrated in Fig. 15, where the maximum excess loss is 0.8233 dB. The experimental results show that the designed coupler has a wide range of wavelength responses.

### 3 Analysis of the Designed Couplers

The simulated and experimental results indicate that X coupler has a lower fabrication tolerance and a relatively larger size. Its splitting ratio is highly sensitive to the parameters of the coupling region. Given the same footprint, a CGC has relatively smaller loss and nonuniformity. Thus, CGCs can be used as alternatives to X couplers. However, a CGC depends greatly on the wavelength and is sensitive to polarization. MMI couplers have several advantages such as their compact construction, low loss, simple fabrication technique, high fabrication tolerance, high uniformity, and small size. Thus, MMI couplers are widely used in planar lightwave circuits. As mentioned in Sec. 1, Chen’s coupler has advantage of a wide bandwidth, but its footprint is large. The respective couplers designed by Yang and Tanaka have small footprints but have relatively large excess loss and nonuniformity. Our MMI coupler ($w = 6 \mu m$) features the combined advantages of low excess loss and high uniformity, with a small footprint and wide bandwidth.

![Fig. 15](image4.png)

**Fig. 15** Output power for the MMI coupler when $w = 6 \mu m$.

### 4 Conclusion

This paper introduces the fabrication and experimental results of a $2 \times 2$ coupler designed with silicon photonic nanowires for the AWG demodulation integration microsystem. Three kinds of $2 \times 2$ couplers are fabricated and tested. Compared with the CGC and the X coupler, the MMI coupler has the advantages of a smaller footprint, lower loss, wider bandwidth, and high fabrication tolerance. When the center wavelength is 1.55 $\mu m$, the designed MMI coupler, with a total footprint of $6 \times 100 \mu m^2$, has an excess loss of 0.5423 dB and a uniformity of 0.0063 dB according to the experimental results. The maximum excess loss of this coupler is 0.8233 dB within the range of 1520 to 1580 nm. Thus, the MMI coupler can meet optoelectronic integration requirements.

### Table 5  Comparison of MMI coupler properties when $w = 6 \mu m$.

<table>
<thead>
<tr>
<th></th>
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<td>3.4960</td>
<td>0.46</td>
</tr>
<tr>
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<td>0.0053</td>
<td>3.5495</td>
<td>3.5558</td>
<td>0.5423</td>
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</table>

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References

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